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Investigation of a Quantum Dot Vertical **External-Cavity Surface-Emitting Laser: Towards THz Frequency Generation**



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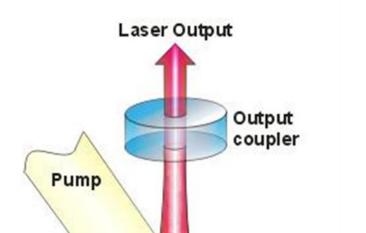
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Introduction

The Terahertz (THz) frequency domain is attractive due to many applications in imaging, sensing and communication. **Problem:** Few efficient room temperature THz sources are available **Solution:** Coherent dual wavelength QD based VECSEL for the THz generation by wavelength beating

Why VECSEL ?

- Low intensity and phase noise
- **High output power (W)**
- **Possible Electrical injection**



Telecom wavelength (centered at 1550 nm)

Checked by

Weak Coupling between **QDs (low density)**

Requirements for the QDs

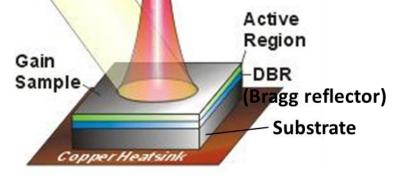
Checked by

Coupling estimation (measurement of the Homogeneous linewidth)

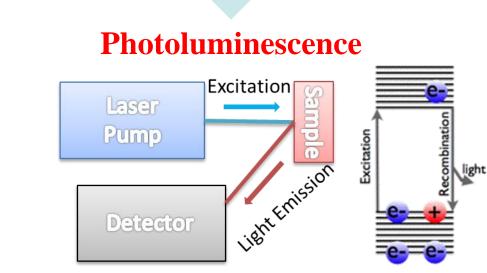
Followed by



- Cavity engineering
- Low wavelength linewidth (kHz)



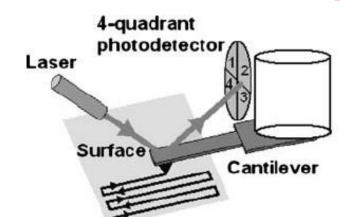
Schematic of an optically pumped VECSEL **VECSEL:** ideal for stable coherent dual wavelength laser but requires weak mode coupling **QDs**

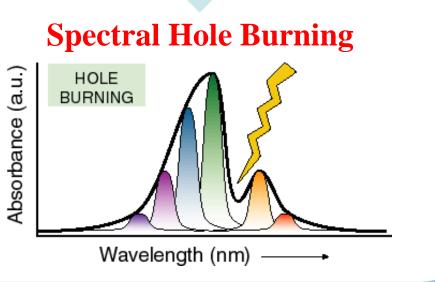


For AFM purposes

Substrate

Atomic Force Microscopy





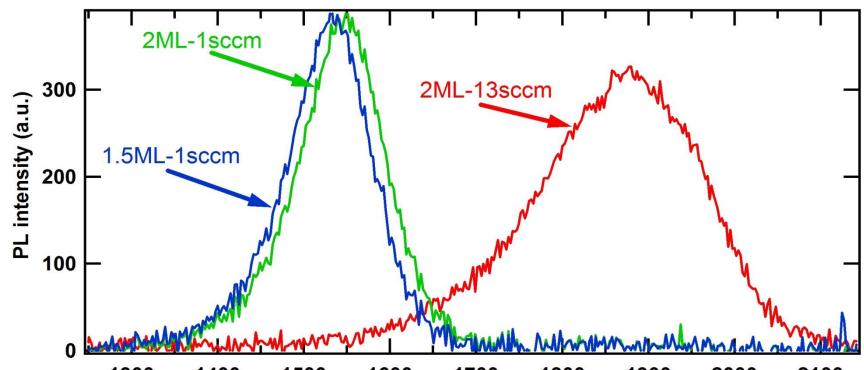
Photoluminescence & Atomic Force Microscopy **Preliminary results**

Molecular Beam Epitaxy (MBE) Growth parameters:

- The Arsenic Flow (Standard Cubic Centimeter per Minute)
- The quantity of deposited InAs (1 MonoLayer = 0.3 nm)

Schematic cross view of the gain medium grown by MBE

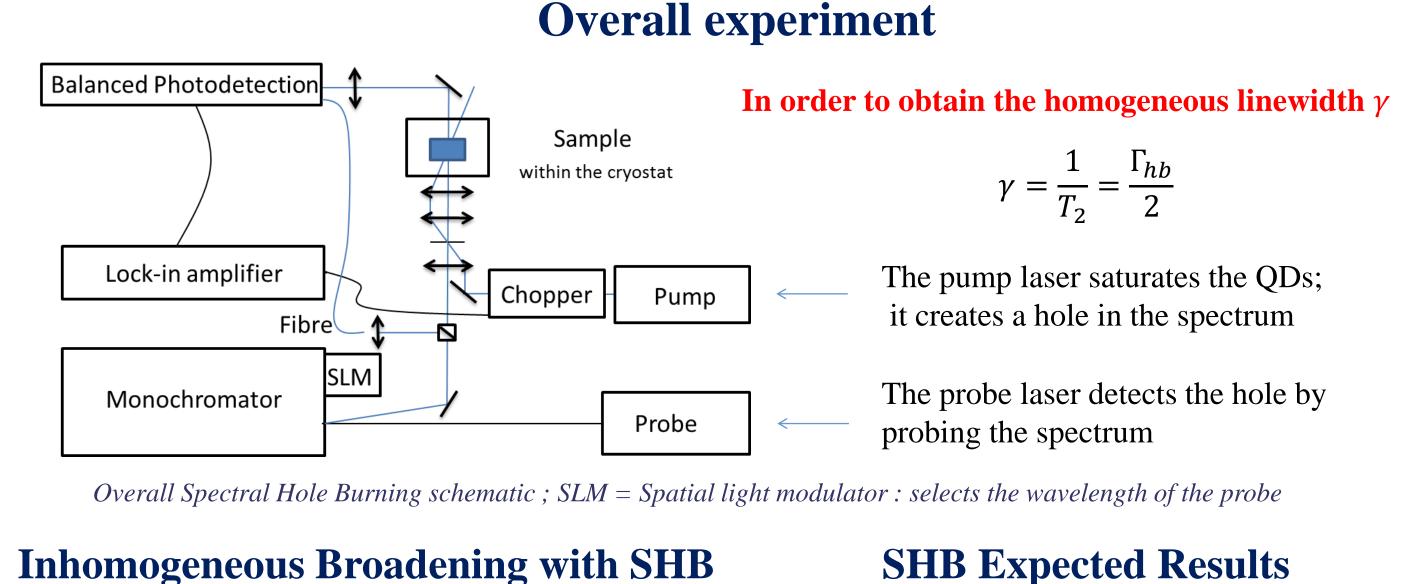




Increase of the quantity of deposited InAs & Arsenic flow \rightarrow higher emission wavelength (lower energy) & bigger QDs

 \rightarrow Stronger evolution with As Flow

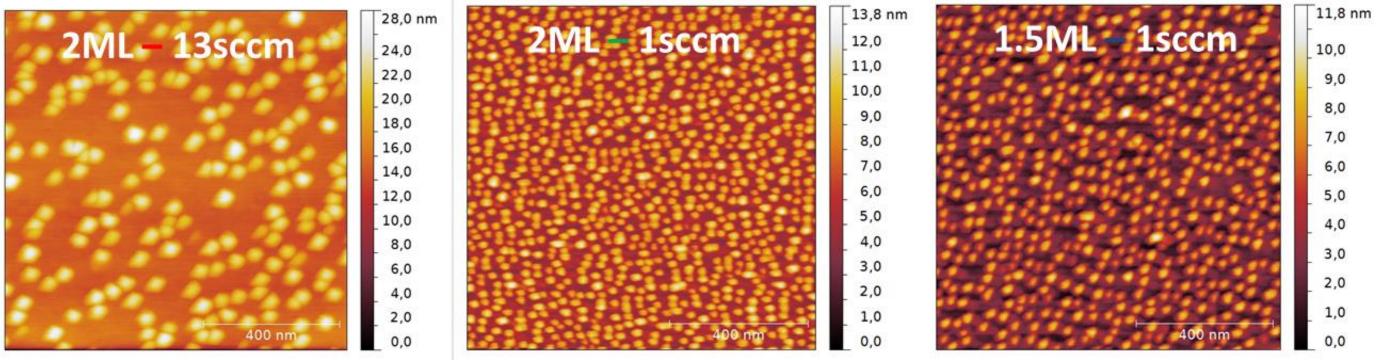
Saturation Spectroscopy : Spectral Hole Burning (SHB)



SHB Expected Results $0.5 \quad 0.6 \quad 0.7 \quad 0.8 \quad 0.9 \quad 1 \quad 1.1 \quad 1.2 \quad 1.3 \quad 1.4$ 0.40.20.15 $\overline{}$

1700 1800 1900 2000 2100 Wavelength (nm) Photoluminescence spectra of InAs QDs for different growth parameters

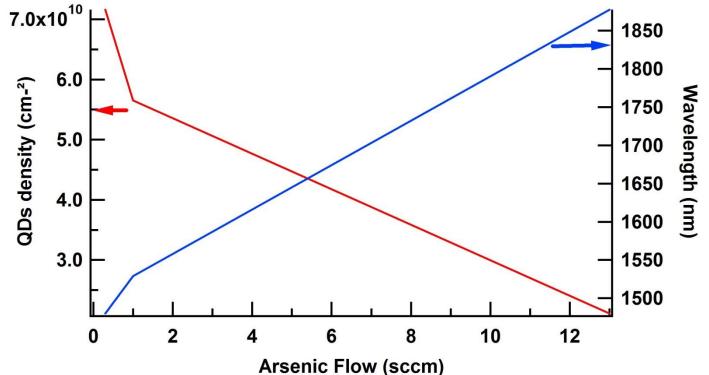
Atomic Force Microscopy



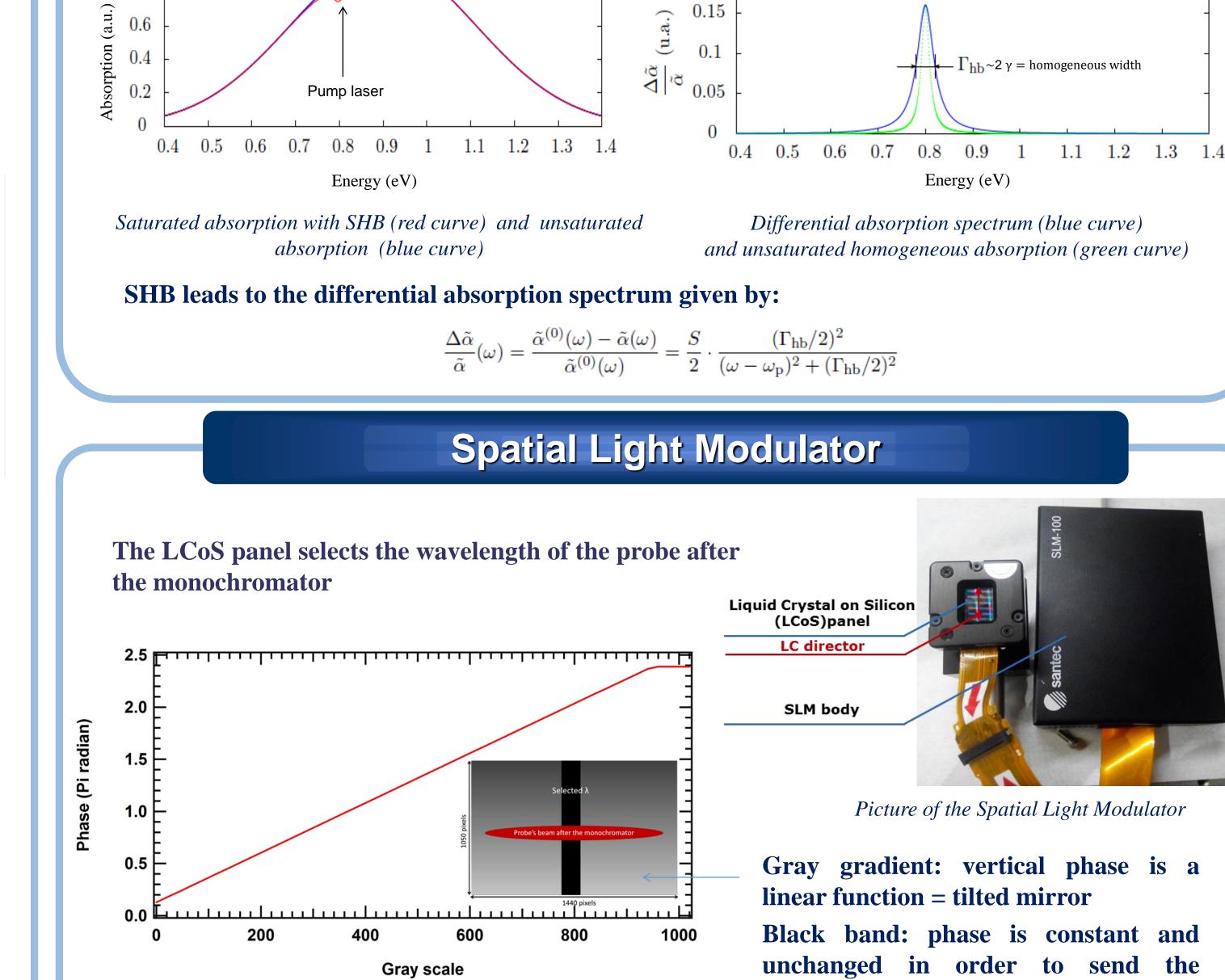
AFM images (1x1 µm²) of the InAs/InP Quantum Dots which have different growth parameters

When the quantity of deposited InAs increases, the density increases and saturates Ο When the Arsenic Flow increases, the QDs get bigger and the density greatly decreases Ο

Overview: Results so far



As Flow (sccm)	InAs deposited (ML)	Central Wavelength (nm)	Density (cm- ²)
0.3	1.5	1480	7.16E+10
0.3	2	1514	9.20E+10
0.3	2.5	1470	5.02E+10
1	1.5	1530	5.56E+10
1	2	1547	9.85E+10
1	2.5	1578	1.32E+10
13	1.5	1877	2.11E+10
13	2	1880	2.31E+10
13	2.5	1945	2.90E+10



For 1.5 ML: QDs density and wavelength as a function of As Flow

Conclusion

Conclusions:

- QDs density (and coupling) mainly controlled by the As flow: changed from 10×10^{10} down to $10^{10} cm^{-2}$, with a strong effect on the wavelength emission: from 1500 nm to 1945 nm
- **Possible growth of InAs/InP QDs with high emission wavelength (1945 nm)**
- Use of a calibrated at 1550nm Spatial Light Modulator for selecting the probe's wavelength during SHB experiment

Perspectives:

- Realisation of SHB in order to get the homogeneous linewidth broadening as a function of QDs density, temperature, input power
- **VECSEL** optical characterization
- **Further development: towards electrical injection**



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required wavelength on the sample